

Micro Pattern Gaseous Detector: GEM & μ RWELL

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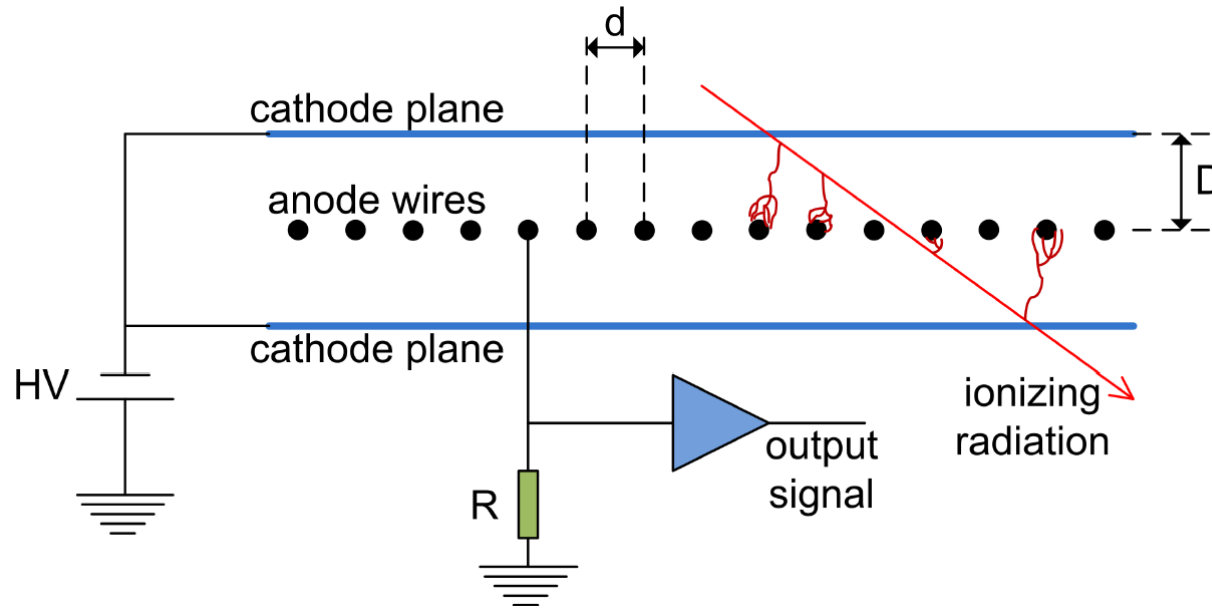
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입자검출기 워크샵 @ IBS

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 - Limitation of MWPC
 - MSGC
 - MM and R-MM
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1. Path to GEM & μ RWELL: MWPC



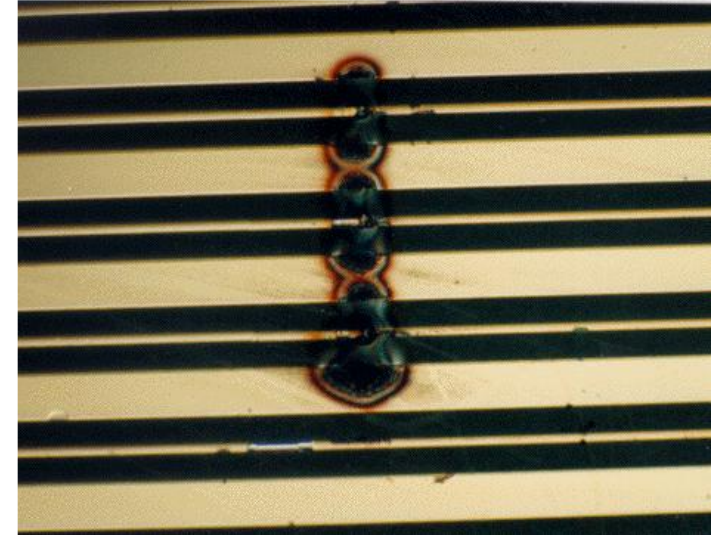
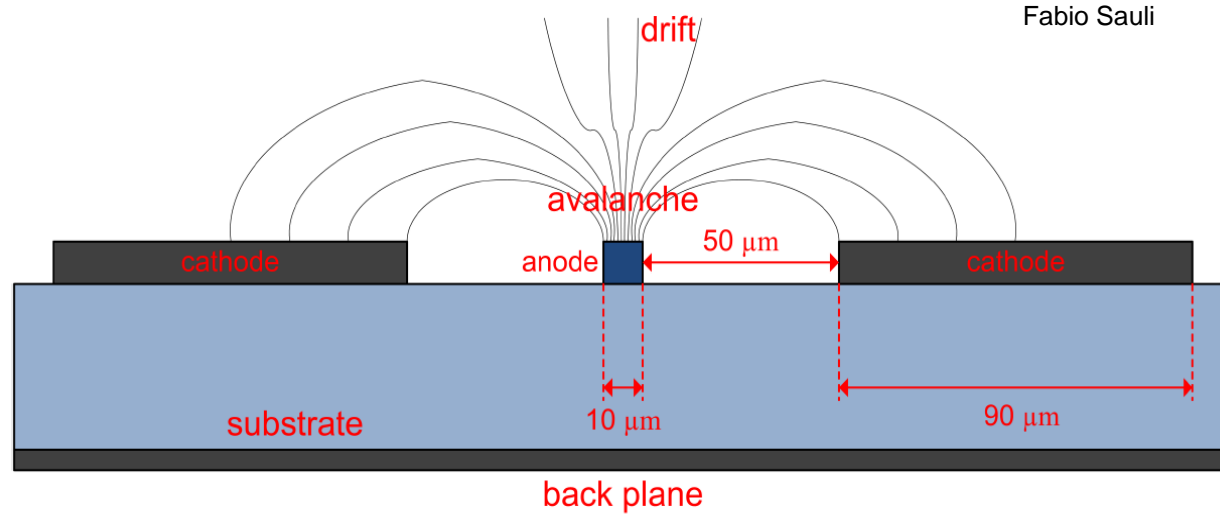
- Limitation of MWPC

- Limited multi-track resolution $\sim O(2-2.5 d)$
- Not enough rate capability $\sim O(v_{ion}/D)$
- Not possible to decrease d and D due to wire buckling

⇒ Clear motivation for micro pattern electrode!

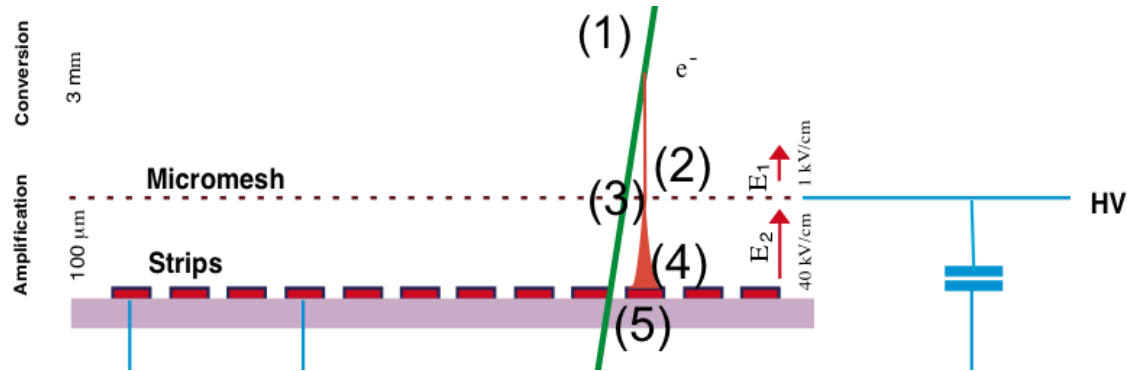
- Not mass production friendly

1. Path to GEM & μ RWELL: MSGC



- $\times 100$ ($\times 20$) better rate capability (multi-track resolution) than MWPC
 - Also mass production friendly
- Short circuit problems caused by carbon paths formed on the substrate due to discharge

1. Path to GEM & μ RWELL: MM and R-MM



- Key concept of MM

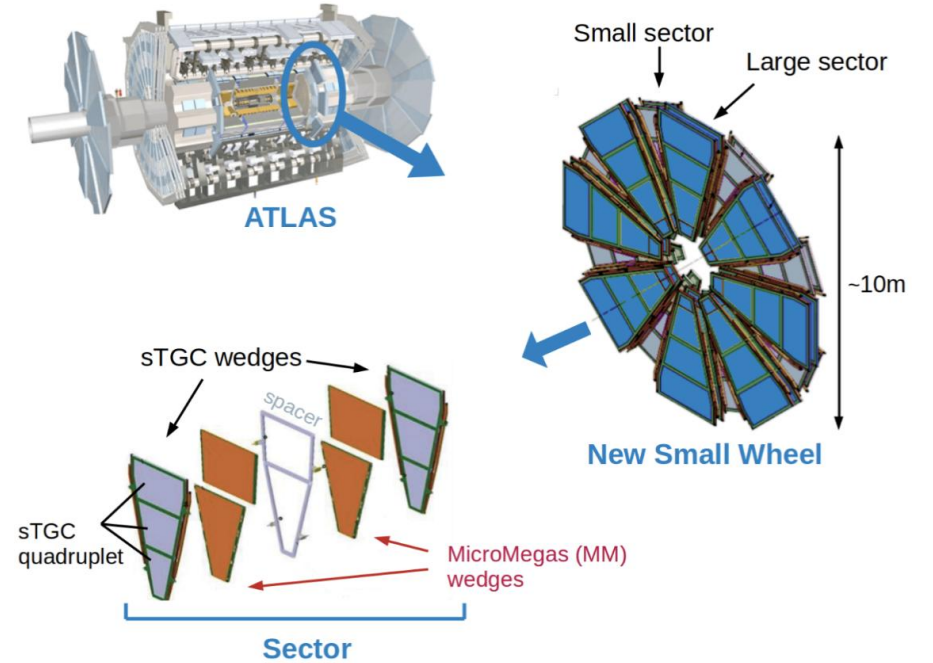
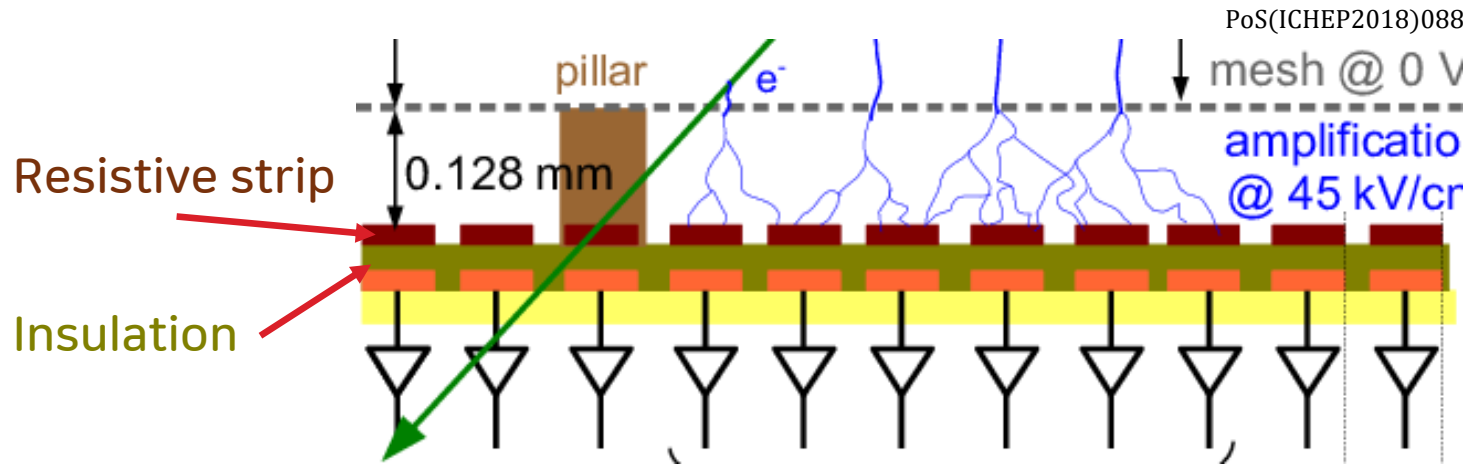
- If direct discharge on the substrate is causing carbon buildup, why not just lift the avalanche region off the surface?

- While the sensor achieved discharge tolerance, the readout electronics remained vulnerable

- Experience of COMPASS

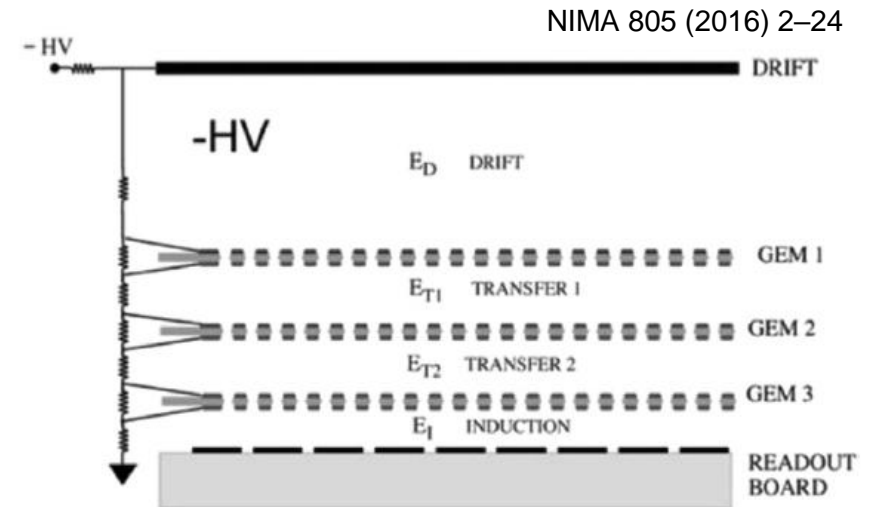
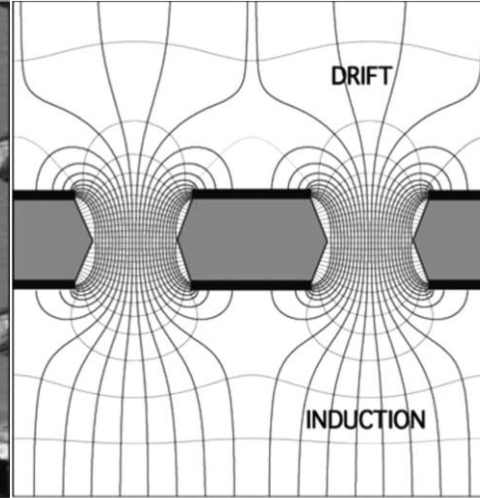
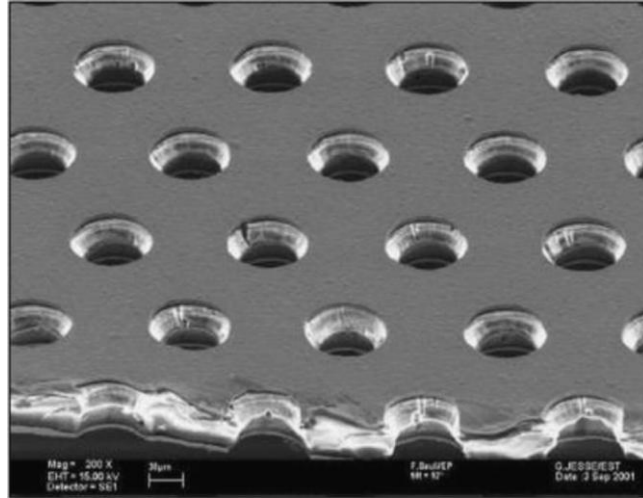
⇒ Resistive MM!

1. Path to GEM & μ RWELL: MM and R-MM

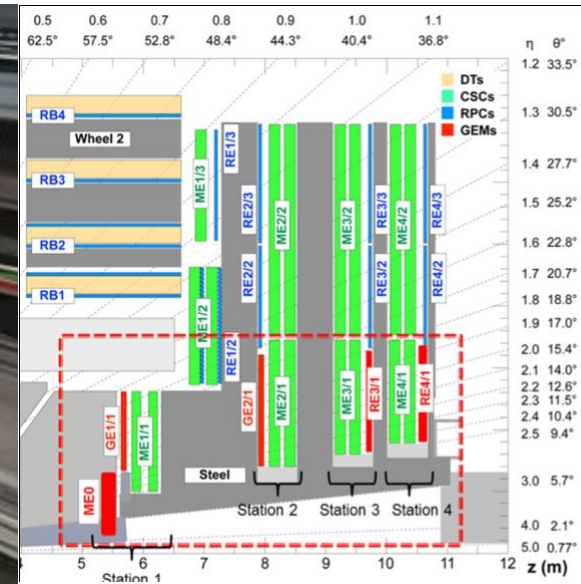
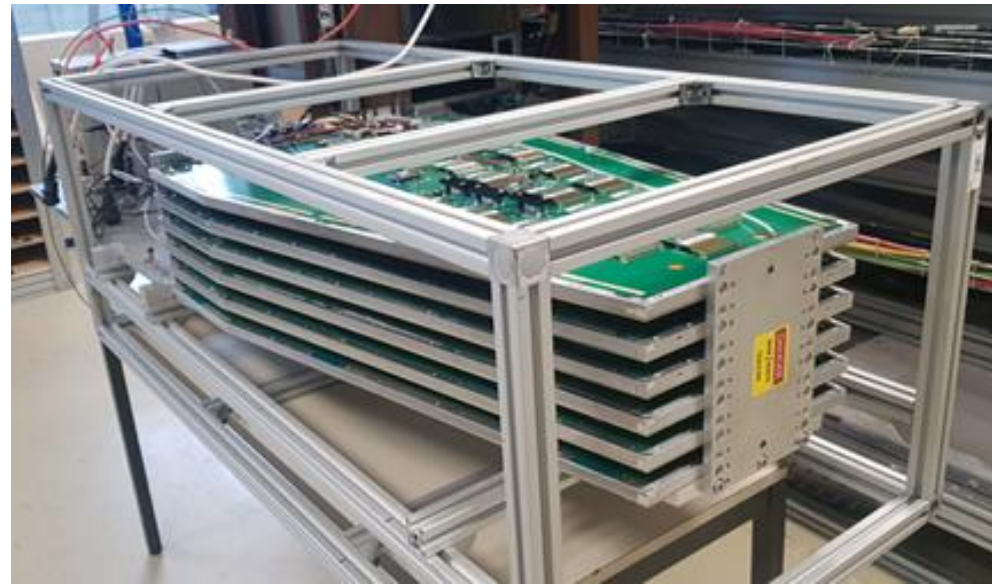


- The resistive anode strip induces a local voltage drop upon streamer formation, effectively quenching the discharge
 - RO electronics are protected!

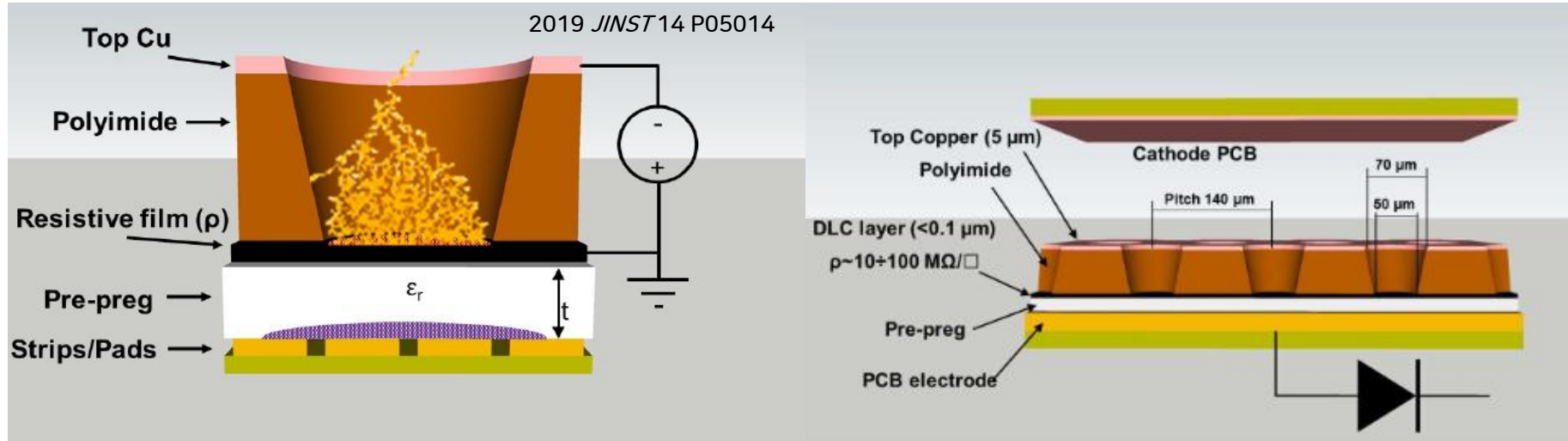
2. GEM



- Step-by-step amplification & separation of induction and amplification region
 - Extremely high rate capability
 - Extremely robust to aging



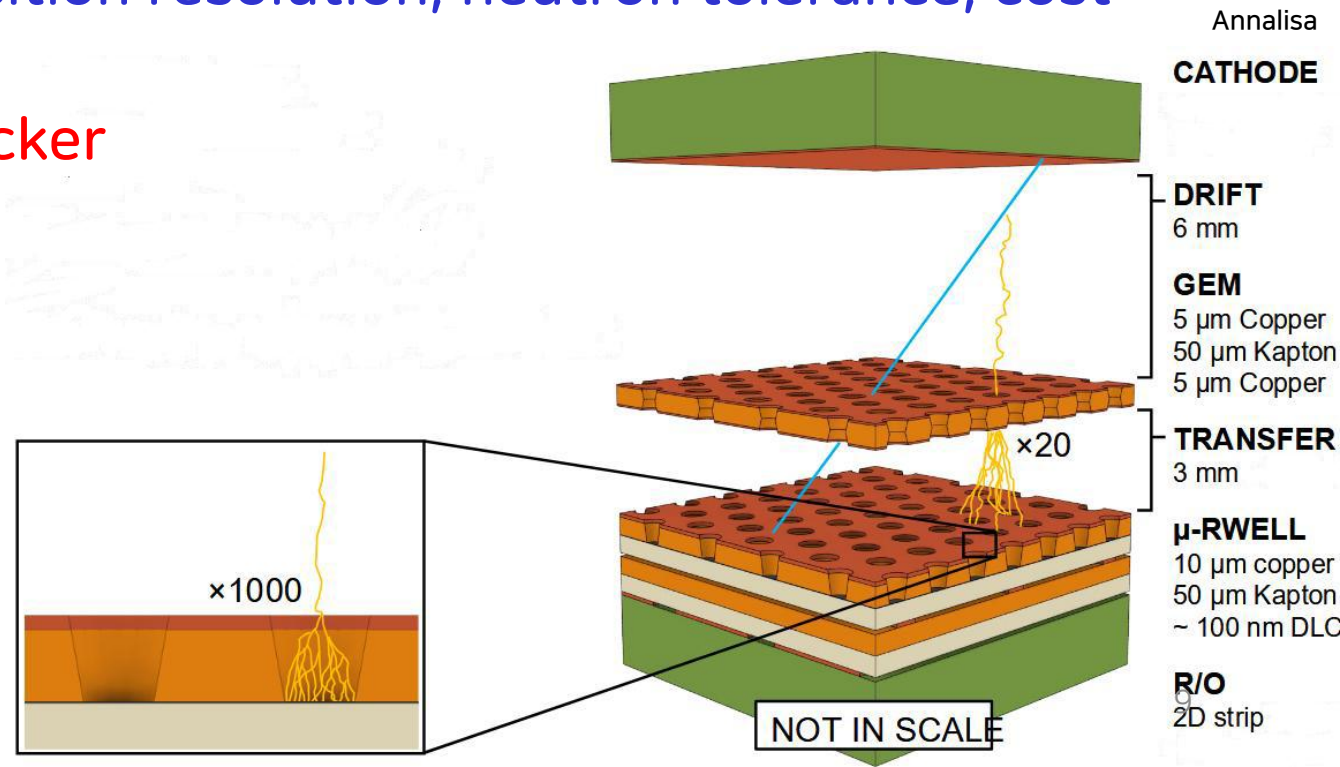
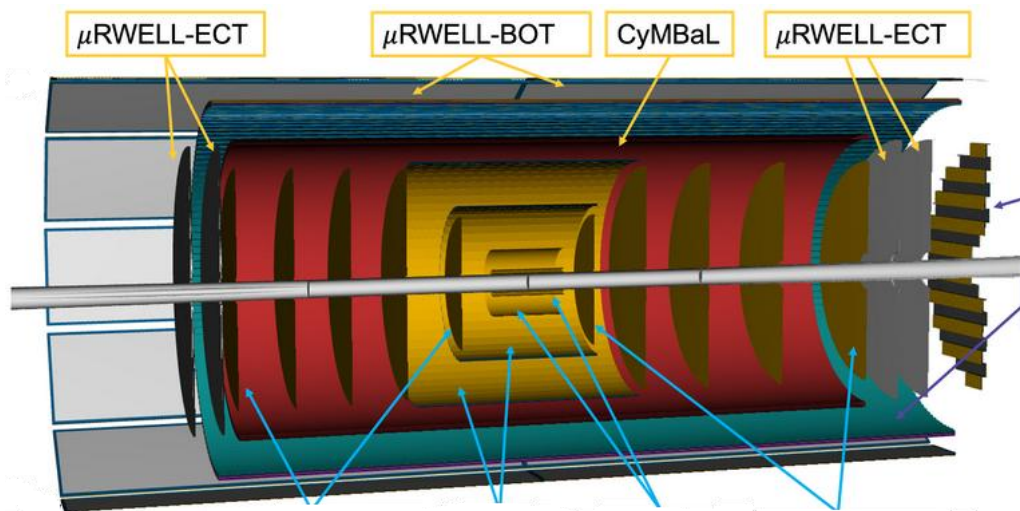
3. Resistive GEM - μ RWELL



- Micro resistive well, the resistive variant of GEM
 - Structurally simple and robust
 - Faster assembly and low material budget
 - Industry-friendly because it is based on standard PCB technology mostly
 - ⇒ Cost-effective
- However, having CERN as the single supplier creates a severe bottleneck in procurement

3. Resistive GEM - μ RWELL

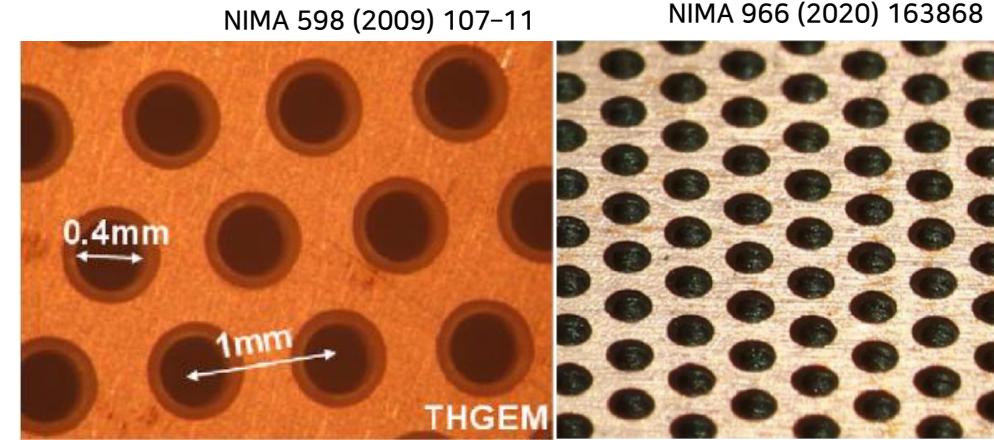
- Experiment planning to use μ RWELL
 - **ePIC central tracker:** GEM+ μ RWELL hybrid, low material budget
 - **LHCb muon tracker:** GEM+ μ RWELL hybrid, replacing MWPC due to Lumi. upgrade, high rate μ RWELL
 - **CLAS12 tracker:** replacing DC due to Lumi. upgrade, high rate μ RWELL
 - **DAMSA tracker & pre-shower:** good position resolution, neutron tolerance, cost effective
 - **IDEA @ FCC-ee pre-shower & muon tracker**



4. Other MPGDs

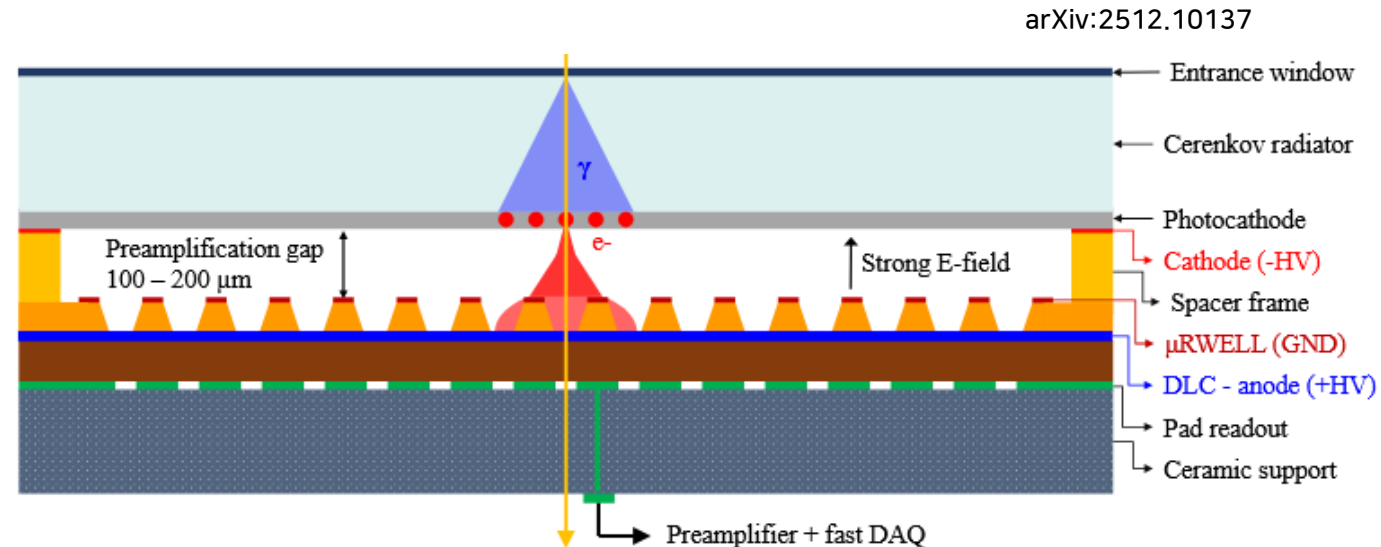
- THGEM

- Robust, high gain, cheap, mass production friendly
- Poor multi-track resolution, charging up, discharge
- Glass THGEM?



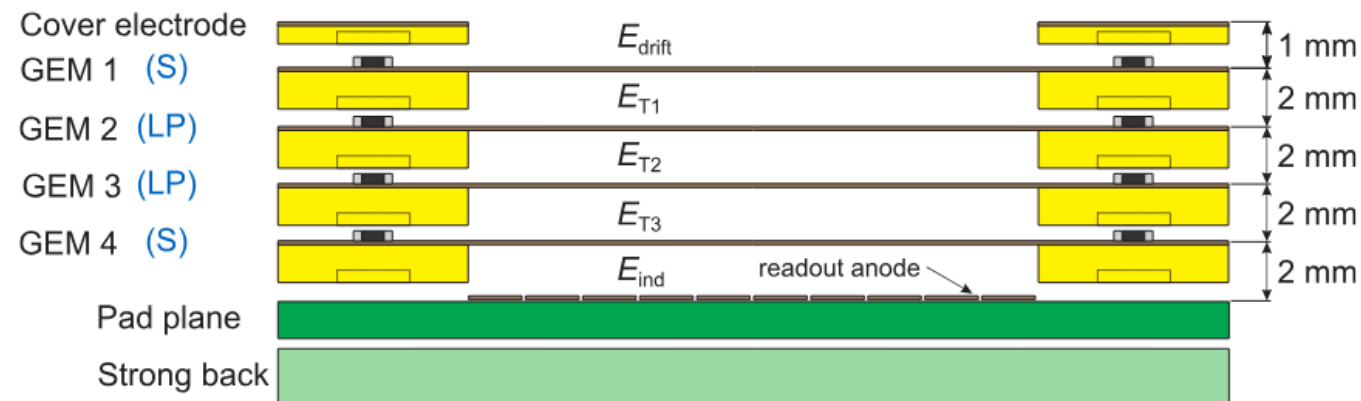
- PICOSEC

- Cherenkov+photoelectric+MPGD
- ~20 ps for Csl or
~ 35 ps for DLC photocathode



5. GEM vs. μ RWELL vs. R-MM

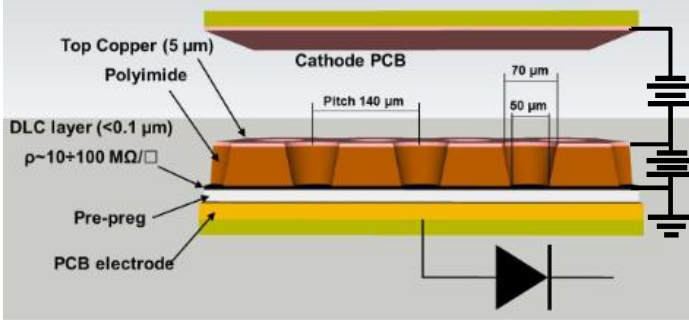
- In general, GEM, R-MM and μ RWELL exhibit comparable performance
 - Position resolution: $\sim 60 \mu m$
 - Energy resolution: R-MM $\sim \mu$ RWELL $>$ GEM
 - Time resolution: R-MM $\sim \mu$ RWELL $>$ GEM
- Aging: GEM \gg R-MM $\sim \mu$ RWELL
- Ion back flow: μ RWELL $>$ R-MM $>$ GEM
 - The ALICE continuous TPC achieved an ion backflow of 0.7% using 4 GEM readout



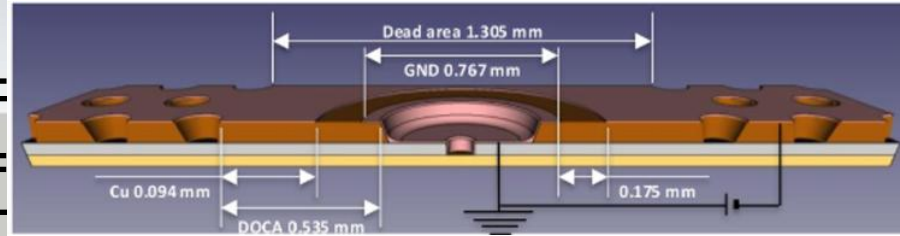
5. GEM vs. μ RWELL vs. R-MM

- Rate capability: $\text{GEM} > \mu\text{RWELL} \sim \text{R-MM}$
 - GEM: voltage drop @ protection resistor, resistive detectors: voltage drop @ resistive layer

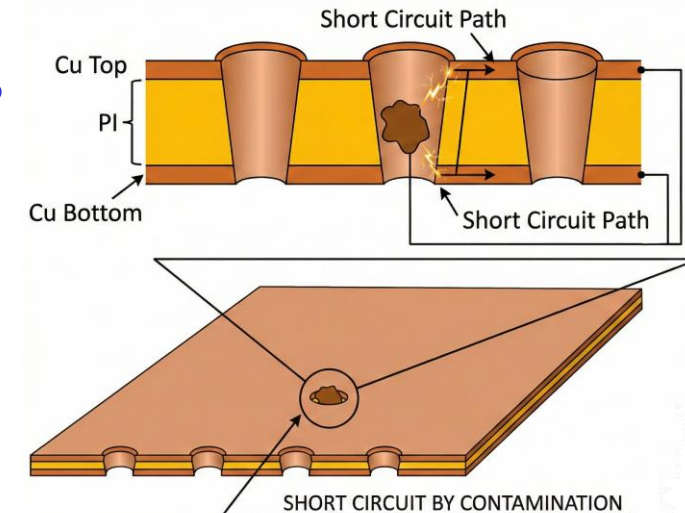
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arXiv:2411.13734

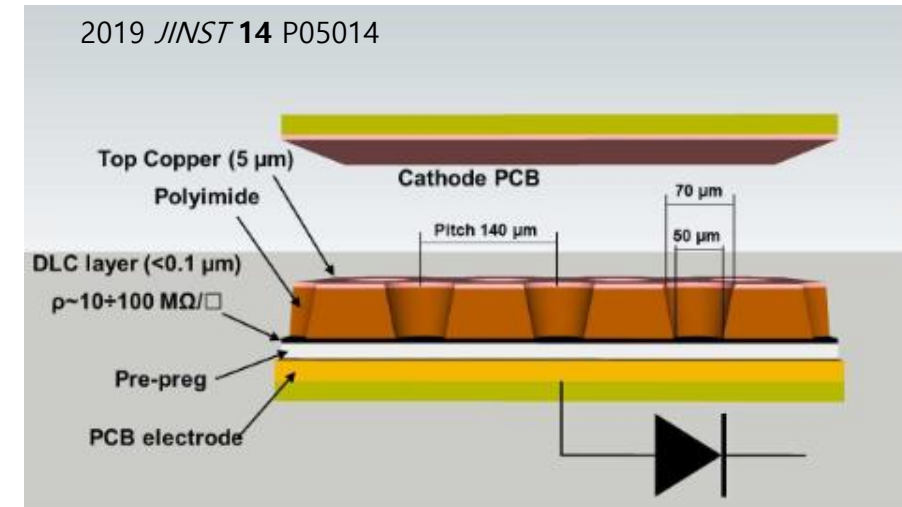
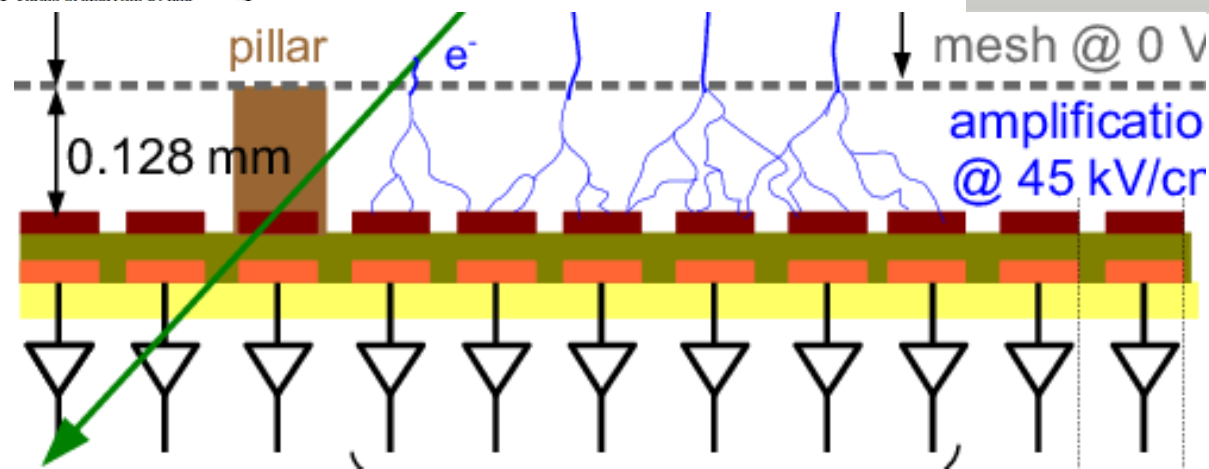
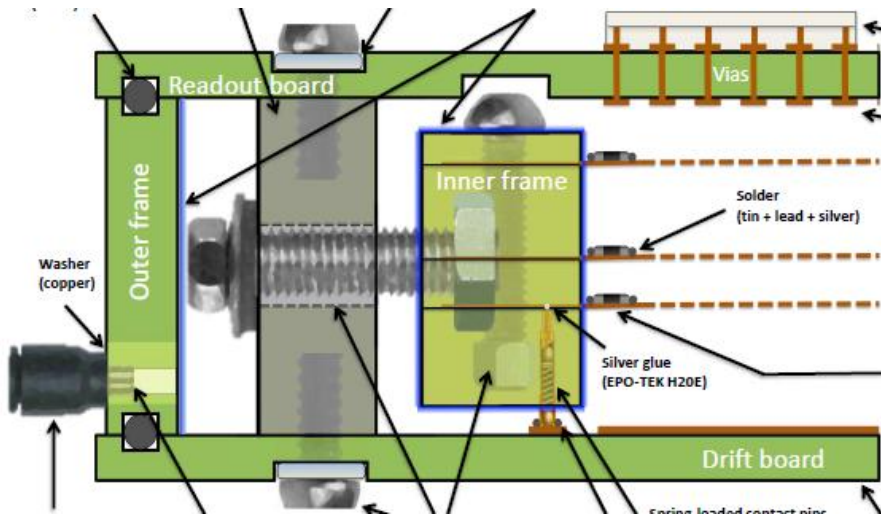


- Sector loss due to short circuit: $\mu\text{RWELL} \sim \text{R-MM} \ll \text{GEM}$
 - A short circuit causes a full sector loss in GEMs, while it results in only a point loss for resistive detectors



5. GEM vs. μ RWELL vs. R-MM

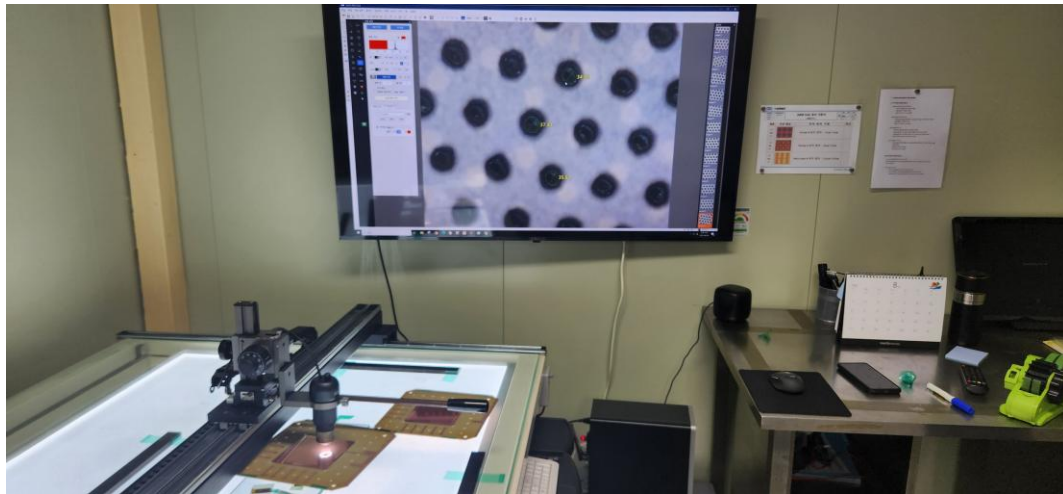
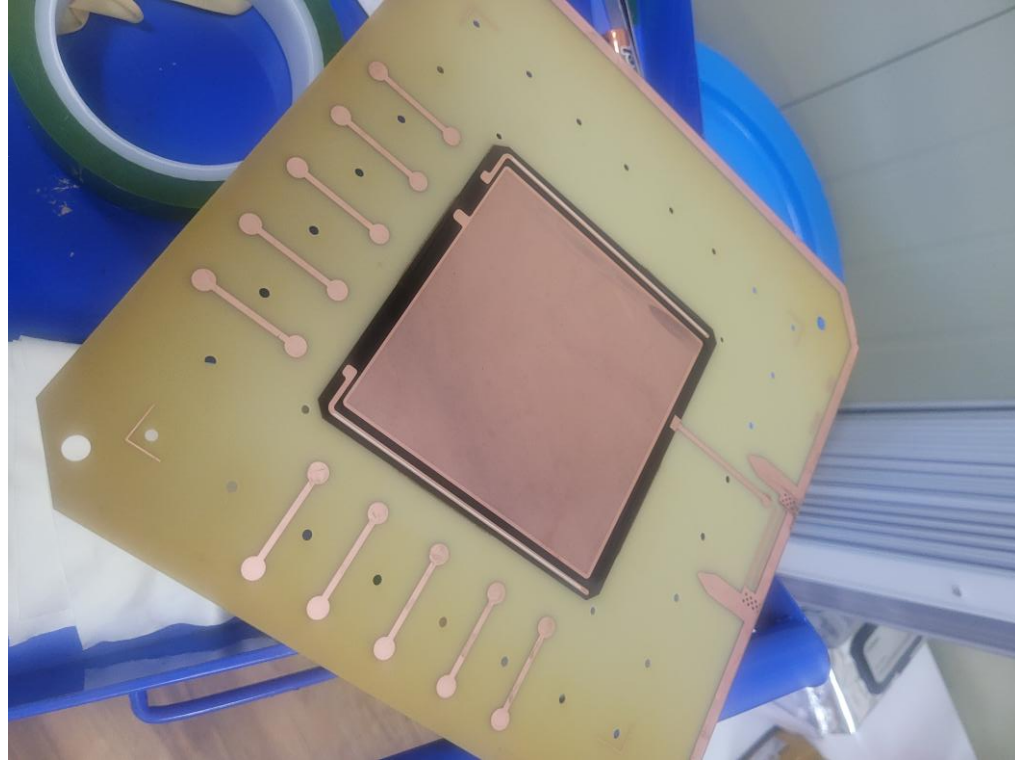
- Structural complexity: μ RWELL \ll R-MM $<$ GEM
 - So is material budget
 - Flexible μ RWELL using FPC based readout



6. Outlook

- μ RWELL is expected to become the most important detector in the MPGD
- The popularity of GEM is expected to decline significantly compared to now
 - μ RWELL is expected to replace a large share of GEM
 - No upcoming experiments that require the exceptional rate capability and aging resistance of GEM
 - Could GEMs be used as imaging detectors in industrial applications outside of physics?
 - Nevertheless, GEM technology will remain relevant for TPC and pre-amplifier
- R-MM usage may decline a bit, but it will continue to be a staple technology

7. R&D Status



Summary

- Efforts to improve the multi-track resolution and rate capability of gas detectors led to the birth of MPGD
- While various MPGDs are being researched, the most widely adopted technologies are GEM, R-MM, and μ RWELL
- I believe μ RWELL will become the most significant technology in the MPGD
 - Working on μ RWELL production research using the GEM manufacturing infrastructure available in Korea